

Crack Tip Energy Release Rate During Fast Fracture Talk given at ICM-6, Kyoto, Japan

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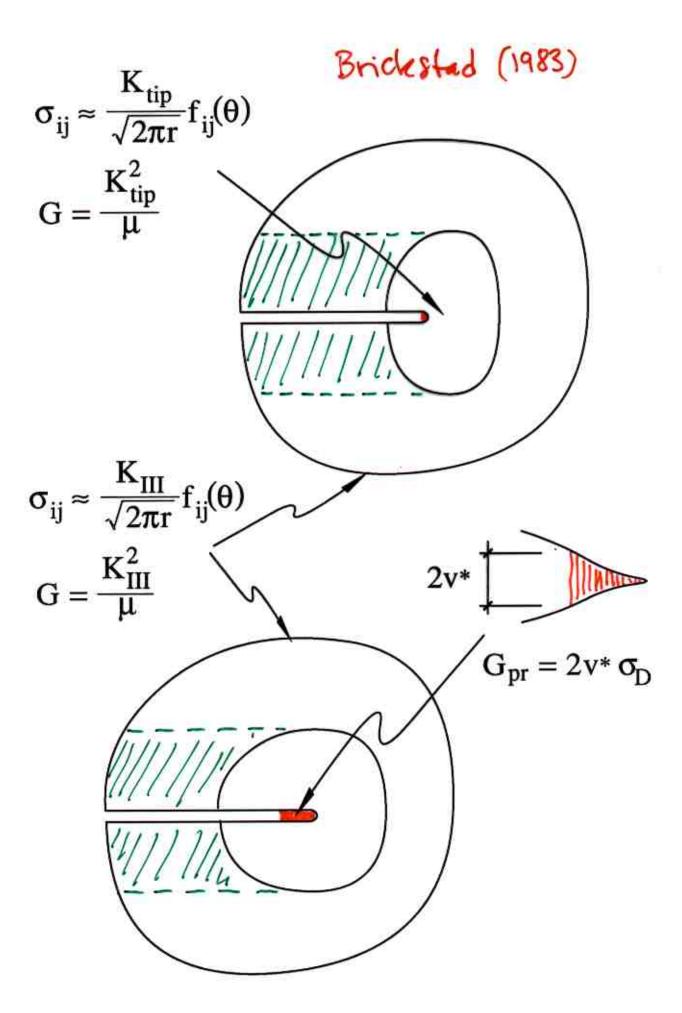
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CRACK TIP ENERGY RELEASE RATE DURING FAST FRACTURE

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- Visco-plastic Model; n<3
 - · Dynamic Steady-State
 - · Mode III
- Asymptotic Field
 vs.
 Line Model for Process Region



$$\begin{split} &\mu\frac{\partial \dot{w}}{\partial x}=\dot{\tau}_{xz}\,+\,\dot{\gamma}_{o}\tau_{Y}\!\!\left(\frac{\tau}{\tau_{Y}}-1\right)^{n}\frac{\tau_{xz}}{\tau}\\ &\mu\frac{\partial \dot{w}}{\partial y}=\dot{\tau}_{yz}\,+\,\dot{\gamma}_{o}\tau_{Y}\!\!\left(\frac{\tau}{\tau_{Y}}-1\right)^{n}\frac{\tau_{yz}}{\tau} \end{split}$$

$$\frac{\partial \dot{\tau}_{xz}}{\partial x} + \frac{\partial \dot{\tau}_{yz}}{\partial y} = \mu m^2 \frac{\partial^2 \dot{w}}{\partial x^2}$$

$$m = \frac{\dot{a}}{c_s}$$
 and $\alpha = (1 - m^2)^{\frac{1}{2}}$

$$\begin{split} &\frac{\partial^2 \dot{w}}{\partial x^2} + \frac{\partial^2 \dot{w}}{\alpha^2 \partial y^2} = \\ &\frac{\lambda \dot{a} \tau_t^2}{\alpha^2 K_{III}^2} \bigg\{ \frac{\partial}{\partial x} \bigg[\Big(\frac{\tau}{\tau_Y} - 1 \Big)^n \frac{\tau_{xz}}{\tau} \bigg] + \frac{\partial}{\partial y} \bigg[\Big(\frac{\tau}{\tau_Y} - 1 \Big)^n \frac{\tau_{yz}}{\tau} \bigg] \bigg\} \end{split}$$

$$\lambda = \frac{\dot{\gamma_o} K_{III}^2}{\dot{a} \tau_y \mu}$$

$$\dot{\mathbf{w}} = \dot{\mathbf{w}}_0 + \lambda \dot{\mathbf{w}}_1 + \mathbf{O}(\lambda^2) \dot{\mathbf{w}}_2$$

$$\tau_{xz} = \tau_{xz0} + \lambda \tau_{xz1} + \mathbf{O}(\lambda^2) \tau_{xz2}$$

$$\tau_{yz} = \tau_{yz0} + \lambda \tau_{yz1} + \mathbf{O}(\lambda^2) \tau_{yz2}$$

Consumed energy alt. analytically determined

Sharp Crack Tip

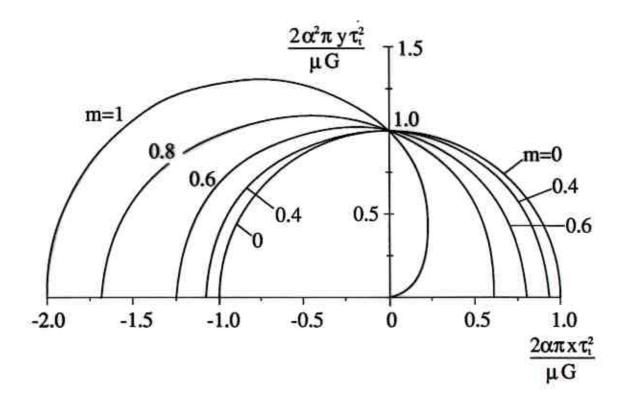
$$\tau_{xz0} = \frac{K_{III}}{\alpha\sqrt{2\pi r}}\sin\left(\frac{\theta}{2}\right) + \mathcal{O}(r)^{\frac{3}{2}}$$

$$\tau_{yz0} = \frac{K_{III}}{\sqrt{2\pi r}} \cos\left(\frac{\theta}{2}\right) + \mathcal{U}(r)^{\frac{3}{2}}$$

$$\begin{split} &\frac{\partial^2 \dot{w}_1}{\partial x^2} + \frac{\partial^2 \dot{w}_1}{\alpha^2 \partial y^2} = \\ &\frac{\dot{a} \tau_t^2}{\alpha^2 K_{III}^2} \frac{\partial}{\partial x} \! \left[\! \left(\frac{\tau_0}{\tau_Y} - 1 \right)^{\!n} \! \frac{\tau_{xz0}}{\tau_0} \right] \! + \frac{\partial}{\partial y} \! \left[\! \left(\frac{\tau_0}{\tau_Y} - 1 \right)^{\!n} \! \frac{\tau_{yz0}}{\tau_0} \right] \end{split}$$

Hodograph Transform ->

Series Expansion in τ_{xz} - τ_{yz} plane



$$n=1$$

$$\dot{w} = \left\{ \left(\frac{\dot{a}}{\dot{\gamma}_o R} - \frac{1}{3} \right) \dot{\textbf{f}}^{-\frac{1}{2}} + \dot{\textbf{f}}^{\frac{1}{2}} - \frac{2}{3} \dot{\textbf{f}} \right\} \Gamma$$

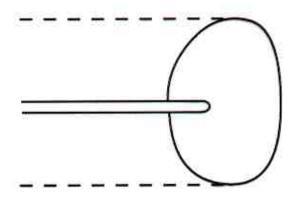
$$n=2$$

$$\dot{w} = \left\{ \left(\frac{\dot{a}}{\dot{\gamma}_o R} - \frac{2}{3} \right) \dot{\beta}^{-\frac{1}{2}} + 2 - 2 \dot{\beta}^{\frac{1}{2}} + \frac{2}{3} \dot{\beta} \right\} \Gamma$$

$$n=5/2$$

$$\begin{split} \dot{w} = & \left\{ \left(\frac{\dot{a}}{\dot{\gamma}_o R} - \frac{5 \tan^{-1}(z)}{4} \right) \dot{\beta}^{-\frac{1}{2}} \right. \\ & \left. + \left(\frac{11}{4} - \frac{13}{6} \dot{\beta}^{\frac{1}{2}} + \frac{2}{3} \dot{\beta} \right)_z \right\}_{\Gamma} \end{split}$$

$$z = \left[\hat{r}^{-\frac{1}{2}} - 1\right]^{\frac{1}{2}}, R = \frac{K_{III}^2}{2\pi\tau_Y^2} \text{ and } \Gamma = \frac{R\dot{\gamma}_0\tau_Y}{\mu}\sin(\frac{\theta}{2})$$



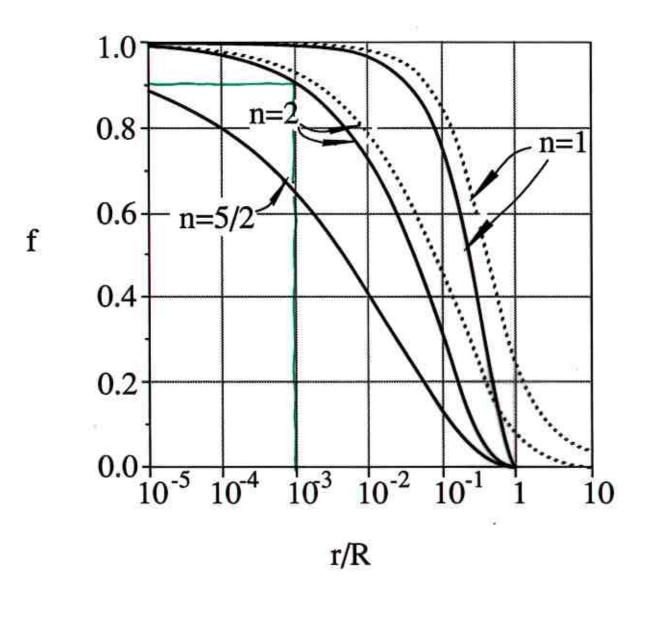
$$\sigma_{ij} \approx \frac{K_{tip}}{\sqrt{2\pi r}} f_{ij}(\theta) + \overline{\sigma}_{ij}$$

$$\overline{\sigma}_{ij} \rightarrow r^{\frac{1}{2}}$$
 for $n = 1$

$$\overline{\sigma}_{ij} \rightarrow r^0$$
 $n = 2$

$$\overline{\sigma}_{ij} \rightarrow r^{-\frac{1}{4}}$$
 $n = \frac{5}{2}$

$$\left(\overline{\sigma}_{ij} \rightarrow r^{-\frac{1}{2}} \log(r) \quad n = 3\right)$$



sharp crack tip

$$f(r) = \frac{\widetilde{K}_{III}(r) - K_{III}}{K_{tip} - K_{III}}$$

$$\widetilde{K}_{III}(r) = \frac{\mu(2\pi r)^{\frac{1}{2}}\dot{w}}{\dot{a}\sin(\frac{\theta}{2})}$$

Line Model for Process Region

$$\tau_{xz0} = \frac{\tau_D}{\alpha\pi} \cosh^{-1} \left(\frac{d + \left[d^2 + r^2 - 2rd\cos(\theta) \right]^{1/2}}{r} \right)$$

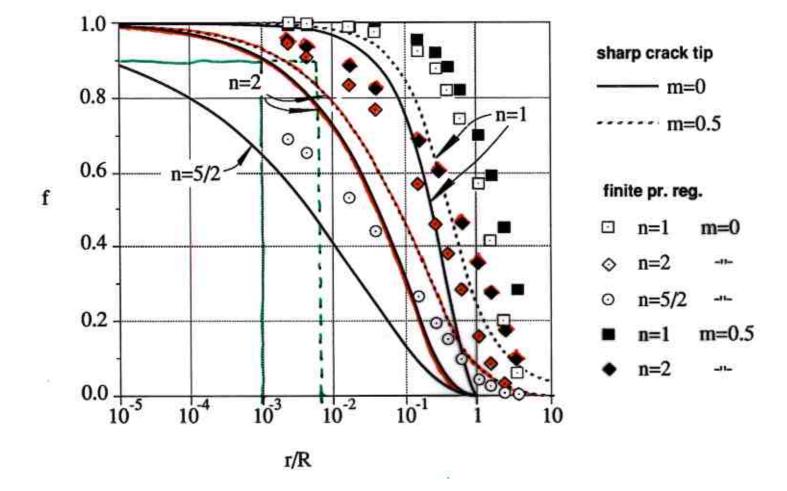
$$\tau_{yz0} = \frac{\tau_{D}}{\pi} \cos^{-1} \left(\frac{d - \left[d^2 + r^2 - 2rd\cos(\theta) \right]^{1/2}}{r} \right)$$

$$d = \frac{\pi}{8} \left(\frac{K_{III}}{\tau_D} \right)^2$$
(fremds himselings)

$$G_{tip} = G - \frac{1}{\dot{a}} \int_{A} (\tau_{xz} \dot{\gamma}_{xz}^{p} + \tau_{yz} \dot{\gamma}_{yz}^{p}) dA - \int_{-R_{max}}^{R_{max}} U_{e}^{*} dy$$

$$G/G_{pr} = 1 + \delta g(m,n) \frac{\dot{\gamma}_o(\mu \rho)^{\frac{1}{2}} G_{pr}}{3\tau_t^2}$$

$$f(d) = \frac{G_{pr}^{\frac{1}{2}}(d) - G^{\frac{1}{2}}}{G_{pr}^{\frac{1}{2}}(0) - G^{\frac{1}{2}}}$$



One condition for using an asymptotic field instead of a detailed model of the process is that the process region is sufficiently embedded in the region where the asymptotic field dominates.

What does sufficiently mean?

It would mean a process region even larger than the region of dominance.